Evidence for the Formation of Diethylsilaneselone: A Reactive Intermediate with a Silicon–Selenium Double Bond

Dennis P. Thompson and Philip Boudjouk*

Department of Chemistry, North Dakota State University, Fargo, North Dakota 58105, U.S.A.

Photolysis of hexaethylcyclotrisilaselenane in the presence of hexamethylcyclotrisiloxane produces tetraethylcyclodisilaselenane and 4,4,6,6,8,8-hexamethyl-2,2-diethyl-1,5,7,3,2,4,6,8-trioxatetrasilaselenocane; diethylsilaneselone is postulated as an intermediate.

The chemistry of reactive intermediates with multiple bonds to silicon has been sufficiently investigated to justify a number of extensive reviews.¹ Such species as silenes ($R_2Si=CR_2$), disilenes (R₂Si=SiR₂), silanimines (R₂Si=NR), silaphosphinimines (R₂Si=PR), silanones (R₂Si=O), and silanethiones $(R_2Si=S)$ have been studied. To our knowledge, there are no reports involving the existence of silaneselones (R₂Si=Se). In

Na₂Se + Et₂SiCl₂ — → Et₂S (1)(2) (40% yield) (30% yield)

Scheme 1

this communication we report chemical evidence for the first member of this family, diethylsilaneselone (Et₂Si=Se).²

Recently, bis(trialkylsilyl)selenides and tellurides were prepared in high yield by the reactions of chlorosilanes with Li₂Se and Li₂Te generated in situ from the chalcogen and lithium triethylborohydride in tetrahydrofuran (THF).³ Using



Na₂Se prepared by a new method⁴ and Et_2SiCl_2 , we were able to prepare the new heterocycles (1) and (2) in isolated yields of 40 and 30% respectively (Scheme 1).[†]

Room temperature photolysis (254 nm) of a hexane solution of (1) for 18 h in the presence of an eight-fold excess of hexamethylcyclotrisiloxane produced (2), and 4,4,6,6,8,8hexamethyl-2,2-diethyl-1,5,7,2,4,6,8,3-trioxatetrasilaselenocane (4) in 70 and 23% yields respectively (Scheme 2). These products are best explained in terms of the extrusion of $Et_2Si=Se$ from (1) and the insertion of this new reactive intermediate into the cyclotrisiloxane to form (4).

Hexamethylcyclotrisiloxane (3) has been used to trap a variety of reactive intermediates with silicon-heteroatom double bonds.⁵ Such reactive intermediates undergo a twoatom insertion into a Si-O bond of the cyclotrisiloxane (Scheme 3).

Photolysis of (1) in hexane in the absence of (3) efficiently produces (2). After 18 h photolysis in the absence of a trap, (1) is completely consumed, producing (2) in >90% yield. The same result occurs when (1) is photolysed in an eight-fold

Spectral data for (3): m/z 388 (M^+ , 2.3%), 373 (M^+ – Me, 9.7%), 359 (M^+ – Et, 100%), with appropriate isotope distribution; ¹H n.m.r., 300 MHz (CDCl₃), δ 1.05–0.8 (m, 10 H, CH₂Me), 0.5 (s, 6 H, Se-SiMe₂), 0.12 and 0.11 (2s, 12 H, O-SiMe₂); ¹³C n.m.r. (CDCl₃), δ 11.74 (CH₂), 7 and 6.8 (-CH₂CH₃ and Se-SiCH₃), 9.1 and 8.8 (O-SiCH₃); ⁷⁷Se n.m.r. (CDCl₃) δ –138.1 p.p.m. Satisfactory elemental analyses were obtained.



excess of Et_3SiH , an efficient silvlene trap, indicating that silvlene formation is not an important pathway in the photochemical decomposition of (1).

Financial support from the Air Force Office of Scientific Research (Grant Number 84-0008) is gratefully acknowledged. We thank Robert West and Gregory R. Gillete of the University of Wisconsin for the selenium-77 n.m.r. data.

Received, 28th November 1986; Com. 1689§

References

- G. Bertrand, G. Trinquier, and P. Mazerolles, J. Organomet. Chem. Libr., 1981, 12, 1; L. E. Gusel'nikov, and N. S. Namekin, Chem. Rev., 1979, 79, 529; A. H. Cowley, Polyhedron, 1984, 3, 389; G. Raabe and J. Michl, Chem. Rev., 1985, 85, 419.
- 2 For a recent review on selenium chemistry see: 'The Chemistry of Organic Selenium and Tellurium Compounds,' vol. 1, eds S. Patai and Z. Rappoport, Wiley, Great Britain, 1986.
- 3 J. A. Gladysz, J. L. Hornby, and J. E. Garbe, J. Org. Chem., 1978,
 43, 1204; M. R. Detty and M. D. Seidler, *ibid.*, 1982, 47, 1354.
- 4 D. P. Thompson and P. Boudjouk, unpublished results.
- R. D. Golino, P. O. Bush, and L. H. Sommer, J. Am. Chem. Soc., 1975, 97, 1957, 7371; H. Okinoshima and W. P. Weber, J. Organomet. Chem., 1978, 149, 279; D. R. Parker and L. H. Sommer, J. Am. Chem. Soc., 1976, 98, 618; L. H. Sommer and J. McLick, J. Organomet. Chem., 1975, 101, 171; H. S. Dilanjan Soysa and W. P. Weber, J. Organomet. Chem., 1979, 165, C1.

§ Revised manuscript received, 1 June 1987.

[†] Spectral data for (1): m/z 495 (M^+ , 14.3%), 467 ($M^+ - \text{Et}$, 6.1%), 303 (Et₃Si₂Se₂+, 100%); with appropriate isotope distribution; ¹H n.m.r. at 90 MHz (CCl₄); δ 1.05 (s, CH₂Me, signal begins to separate in C₆D₆); ¹³C n.m.r. (CDCl₃), δ 13.4 (-CH₂), 7.6 (Me); ²⁹Si n.m.r. (CDCl₃, vs. Me₄Si), δ 25.7 p.p.m.; ⁷⁷Se n.m.r. (CDCl₃, vs. Me₂Se), δ -81.7 p.p.m.; For (2): m/z 332 (M^+ , 27.1%), 303 (M^+ -29, 100%), with appropriate isotope distribution; ¹H n.m.r., 90 MHz (CCl₄), δ 1.00 (s, CH₂Me); ¹³C n.m.r. (CDCl₃), δ 14.4 (-CH₂), 7.4 (Me); ²⁹Si n.m.r. (CDCl₃), δ 8.7 p.p.m.; ⁷⁷Se n.m.r. (CDCl₃), δ -99.9 p.p.m. Satisfactory elemental analyses were obtained. Yields were calculated assuming that 1 mol of (Et₂SiSe)₃ could produce 3 mol of Et₂Si=Se, which could then dimerize or insert into (3).